

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	1378	(438/778).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/11/22 06:46
L2	14	"257"/\$.ccls. and (organic same ((hydrogen or ("H.sub.2")) or methyl) same (methyl or ethyl or propyl or (tertiary adj butyl) or butyl) same (thin adj (film or layer)) same (silicon or ("Si")))) and @ad<="20030213" and (ammonia or ("NH.sub.3")) and (oxygen or ("O.sub.2"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/22 06:55
L3	2	("5840821").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/11/22 06:46
L4	0	2 and hafnium	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/22 06:57
L5	0	2 and (hafnium or ("Hf"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/22 06:56
L6	945	"257"/\$.ccls. and (organic and ((hydrogen or ("H.sub.2")) or methyl) and (methyl or ethyl or propyl or (tertiary adj butyl) or butyl) and (thin adj (film or layer)) and (silicon or ("Si")))) and @ad<="20030213" and (ammonia or ("NH.sub.3")) and (oxygen or ("O.sub.2"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/22 06:56
L7	250	6 and (hafnium or ("Hf"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/22 06:56

L8	58	6 and hafnium	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/22 06:58
L9	4	8 and (thermal adj chemical adj vapor adj deposition)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/22 06:59
L10	8	7 and (thermal adj chemical adj vapor adj deposition)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/22 08:26
L11	1	("20040203255").PN.	US-PGPUB	OR	OFF	2005/11/22 07:09
S1	2	("20040203255").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/11/22 07:09
S2	118956	organic with ((hydrogen or ("H. sub.2")) or methyl) with (methyl or ethyl or propyl or (tertiary adj butyl) or butyl)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/06 14:10
S3	274002	organic same ((hydrogen or ("H. sub.2")) or methyl) same (methyl or ethyl or propyl or (tertiary adj butyl) or butyl)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/06 14:11
S4	357	(organic with ((hydrogen or ("H. sub.2")) or methyl) with (methyl or ethyl or propyl or (tertiary adj butyl) or butyl)) with (thin adj (film or layer))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/06 14:11
S5	6364	organic same ((hydrogen or ("H. sub.2")) or methyl) same (methyl or ethyl or propyl or (tertiary adj butyl) or butyl) same (thin adj (film or layer))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/06 14:12

S6	35	(organic with ((hydrogen or ("H.sub.2")) or methyl) with (methyl or ethyl or propyl or (tertiary adj butyl) or butyl)) with (thin adj (film or layer)) with (silicon or ("Si"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/06 14:12
S7	498	organic same ((hydrogen or ("H.sub.2")) or methyl) same (methyl or ethyl or propyl or (tertiary adj butyl) or butyl) same (thin adj (film or layer)) same (silicon or ("Si"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/06 14:13
S8	23	((organic with ((hydrogen or ("H.sub.2")) or methyl) with (methyl or ethyl or propyl or (tertiary adj butyl) or butyl)) with (thin adj (film or layer)) with (silicon or ("Si")))) and @ad<="20030213"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/06 14:17
S9	124	(organic same ((hydrogen or ("H.sub.2")) or methyl) same (methyl or ethyl or propyl or (tertiary adj butyl) or butyl) same (thin adj (film or layer)) same (silicon or ("Si")))) and @ad<="20030213"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/06 14:18
S10	7	((organic with ((hydrogen or ("H.sub.2")) or methyl) with (methyl or ethyl or propyl or (tertiary adj butyl) or butyl)) with (thin adj (film or layer)) with (silicon or ("Si")))) and @ad<="20030213" and (ammonia or ("NH.sub.3")) and (oxygen or ("O.sub.2"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/06 14:18
S11	34	(organic same ((hydrogen or ("H.sub.2")) or methyl) same (methyl or ethyl or propyl or (tertiary adj butyl) or butyl) same (thin adj (film or layer)) same (silicon or ("Si")))) and @ad<="20030213" and (ammonia or ("NH.sub.3")) and (oxygen or ("O.sub.2"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/06 14:40
S12	5	"438"/\$.ccls. and (organic same ((hydrogen or ("H.sub.2")) or methyl) same (methyl or ethyl or propyl or (tertiary adj butyl) or butyl) same (thin adj (film or layer)) same (silicon or ("Si")))) and @ad<="20030213" and (ammonia or ("NH.sub.3")) and (oxygen or ("O.sub.2"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/06 14:42

S13	13	"257"/\$.ccls. and (organic same ((hydrogen or ("H.sub.2")) or methyl) same (methyl or ethyl or propyl or (tertiary adj butyl) or butyl) same (thin adj (film or layer)) same (silicon or ("Si")))) and @ad<="20030213" and (ammonia or ("NH.sub.3")) and (oxygen or ("O.sub.2"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/22 06:46
S14	0	"438"/778.ccls. and (organic same ((hydrogen or ("H.sub.2")) or methyl) same (methyl or ethyl or propyl or (tertiary adj butyl) or butyl) same (thin adj (film or layer)) same (silicon or ("Si")))) and @ad<="20030213" and (ammonia or ("NH.sub.3")) and (oxygen or ("O.sub.2"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/06 14:41
S15	1272	(438/778).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/11/22 06:46